

**NATIONAL PHASE  
UTILITY APPLICATION**

**Transmittal to the (DO/EO/US)  
Under 35 USC 371**

Attorney Docket No.: SHIGA7.033APC  
First Named Inventor: Hideo Hada  
Int'l Application No.: PCT/JP2004/008004  
Int'l Filing Date: June 2, 2004  
Priority Date Claimed: June 5, 2003  
Title: RESIN FOR PHOTORESIST COMPOSITION,  
PHOTORESIST COMPOSITION AND METHOD FOR  
FORMING RESIST PATTERN  
Express Mail Label No.: EV718233132US

**10/557694**

**Direct all correspondence to Customer No.: 20995**

Date: November 22, 2005  
Page 1 of 3

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Alexandria VA 22313-1450

The following enclosures are transmitted herewith to be filed in the patent application of:

**Inventors:**

- |                    |                     |
|--------------------|---------------------|
| 1. Hideo Hada      | 2. Masaru Takeshita |
| 3. Shogo Matsumaru | 4. Hiroaki Shimizu  |

**APPLICATION ELEMENTS:**

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) A copy of the International Application as filed (35 U.S.C. § 371(c)(2)) has been communicated by the International Bureau.
  - (X) PCT/IB/308 enclosed.
- (X) An English translation of the International Application as filed is attached hereto.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.
- (X) An Oath or Declaration signed by the inventors (35 U.S.C. § 371(c)(4)).

**OTHER APPLICATION PARTS:**

- (X) Preliminary Amendment in 7 pages.
- (X) Application Data Sheet in 4 pages.
- (X) Recordation form cover sheet and Assignment in 3 total pages (cover sheet & assignment).
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
  - (X) Listing 18 references.
  - (X) Enclosing 14 references.
- (X) Cover page of PCT publication WO 2004/108780.
- (X) International Search Report (PCT/ISA/210).

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	<b>Direct all correspondence to Customer No.: 20995</b>	
		Date: November 22, 2005 Page 2 of 3

(X) Written Opinion (PCT/ISA/237).

(X) Return prepaid postcard.

**FILING FEES:**

FEE CALCULATION			
FEE TYPE & DETERMINATION		LARGE FEE	TOTAL
Basic Filing Fee under 1.492(a)		1631 (\$300)	\$300
Search Fee under 1.492(b) (enter one in TOTAL column)			
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1640 (\$0)	\$400
(2) USPTO was the ISA (noncompliant claims)		1641 (\$100)	
(3) Foreign Search Report Enclosed		1642 (\$400)	
(4) No Search Report Enclosed		1632 (\$500)	
Examination Fee under 1.492(c) (enter one in TOTAL column)			
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1643 (\$0)	\$200
(2) Non US IPEA or Noncompliant Claims		1633 (\$200)	
Excess Claims	17 - 20 = 0	1615 (\$50)	0 x 50 = \$0
Excess Ind. Claims	2 - 3 = 0	1614 (\$200)	0 x 200 = \$0
Multiple Dep. Claim		1616 (\$360)	\$0
Application Size Fee	0 - 100 = 0	1681 (\$250)	0 x 250 = \$0
Late English Translation		1618 (\$130)	\$0
Assignment		8021 (\$40)	1 x 40 = \$40
		<b>TOTAL FEE DUE</b>	<b>\$940</b>
<b>TOTAL FEE PAID (If Different Than Fee Due)</b>			<b>\$</b>

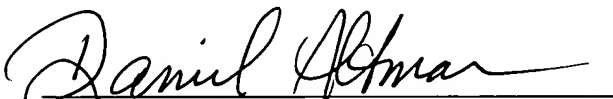
(X) A check in the amount of \$940 to cover the Total Fee Due is enclosed.

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IAP6 Rec'd PCT/PTD 22 NOV 2005

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**CERTIFICATE OF MAILING BY "EXPRESS MAIL"**

**Attorney Docket No.** : SHIGA7.033APC  
**Applicant(s)** : Hada et al.  
**For** : RESIN FOR PHOTORESIST COMPOSITION,  
PHOTORESIST COMPOSITION AND  
METHOD FOR FORMING RESIST  
PATTERN  
  
**Attorney** : Daniel E. Altman  
**"Express Mail" Label No. :** EV718233132US  
**Date of Deposit** : November 22, 2005

I hereby certify that the accompanying

Transmittal letter; English translation of specification in 48 pages; Preliminary Amendment in 7 pages; Application Data Sheet in 4 pages; Declaration/Power of Attorney in 2 pages; Recordation Form Cover Sheet and Assignment in 3 pages; International Search Report and Written Opinion; PTO/IB/308; cover page of PCT publication; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 14 references; Check for Filing Fee; Return Prepaid Postcard

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